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(54) Title: COMPOSITION FOR METAL ELECTROPLATING COMPRISING LEVELING AGENT

(57) Abstract: A composition comprising a source of metal ions and at least one leveling agent obtainable by condensing at least one trialkanolamine of the general formula $N(R^1-OH)_3$ (Ia) and/or at least one dialkanolamine of the general formula $R^2-N(R^1-OH)_2$ (Ib) to give a polyalkanolamine(II), wherein the R^1 radicals are each independently selected from a divalent, linear or branched aliphatic hydrocarbon radical having from 2 to 6 carbon atoms, and the R^2 radicals are each selected from hydrogen and linear or branched aliphatic, cycloaliphatic and aromatic hydrocarbon radicals having from 1 to 30 carbon atoms, or derivatives obtainable by alkoxylation, substitution or alkoxylation and substitution of said polyalkanolamine(II).

